

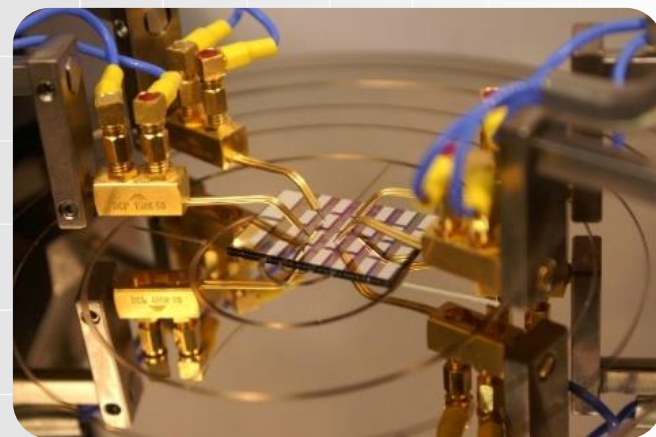


Wrocław
University
of Science
and Technology

Division of Vacuum Technology and Diagnostisc of Nanomaterials

Faculty Electronics, Photonics and Micorsystems

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MSc Eng. Marcin Prządka (applied doctorate)

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MSc Eng. Maurycy Maziuk

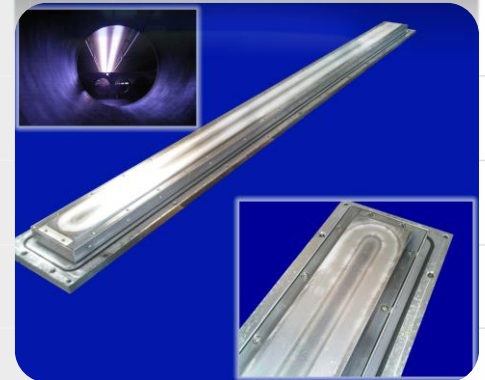
Research activity profile:

Vacuum deposition of thin films by PVD methods (magnetron sputtering, electron beam evaporation)

- metal layers, dielectric and (semi)conducting thin layers,
- composites of metal nitrides, oxides,
- carbides and carbide-nitrides
- microelectronic passive structures for new generation microsensors,
- fabrication of TCO (Transparent Conducting Oxide) and TOS (Transparent Oxide Semiconductor)

Research on plasma deposition processes

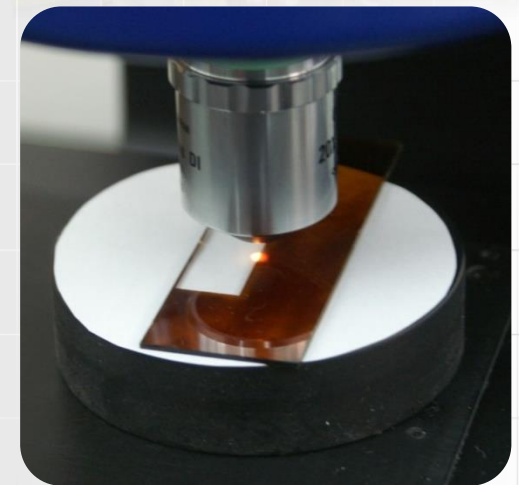
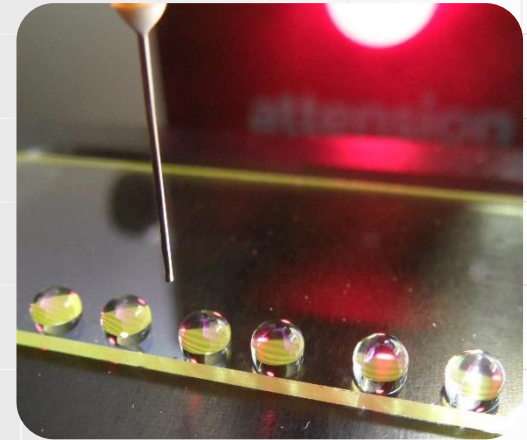
- study of deposition processes of thin film coatings using PVD methods,
- designing, construction, modernisation and manufacturing of vacuum components (electron guns, magnetron guns)



Research activity profile:

Research on thin film optical coatings for different purposes:

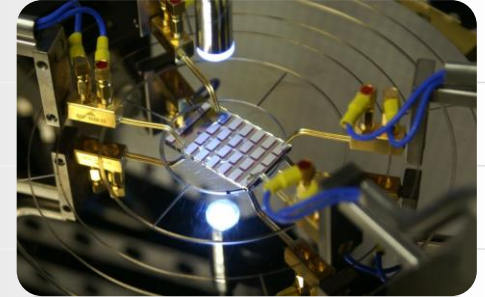
- transparent electronics,
- wear and scratch resistant hard coatings,
- photocatalytic coatings,
- chromogenic coatings,
- luminescence coatings,
- hydrophobic/hydrophilic coatings,
- thin films for photovoltaics,
- antibacterial coatings,
- ... and many more.



Research activity profile:

Diagnostics

- optical properties (transmission/reflection measurements)
 - n&k analysis using reverse engineering method
 - designing of optical thin films
- electrical properties (dc, ac, thermoelectrical, Seebeck, Hall effect measurements)
 - impedance spectroscopy analysis (equivalent circuit models)
 - analysis of electrical charge carriers transport mechanisms
- mechanical properties (abrasion, wear resistance), and surface (topography, wettability) properties
- analysis of microstructure (XRD, Raman spectroscopy, TEM) and surface properties (AFM, XPS, UPS)
- gas sensing and chromogenic properties



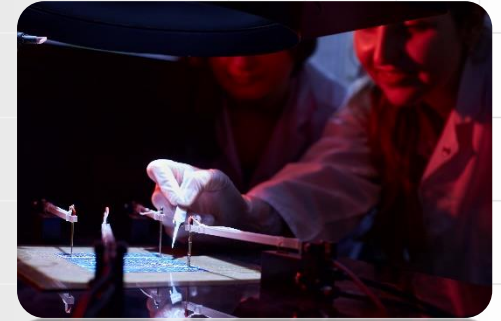
Division structure:

Research Laboratories

- Laboratory of Vacuum and Plasma Technologies
- Laboratory of Thin Film Optical Coatings
- Laboratory of Optical and Electrical Diagnostics of Nanomaterials
- Laboratory of Nanomaterials Technology
- Laboratory of Photovoltaics (SolarLab)

Teaching Laboratories

- Open Laboratory
- Laboratory of Wireless Systems Technology and Internet of Things



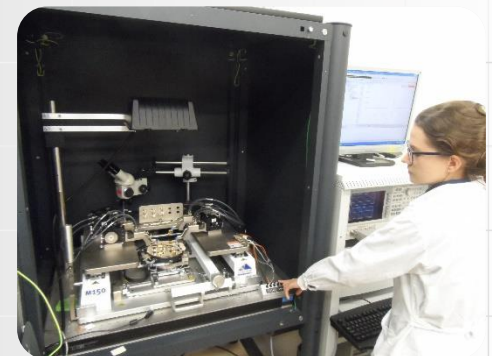
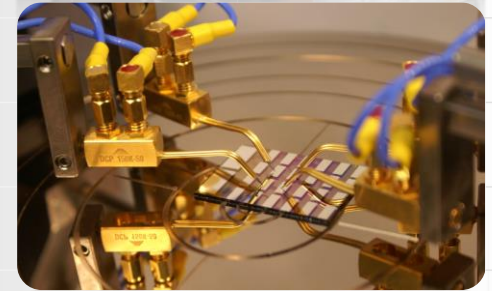
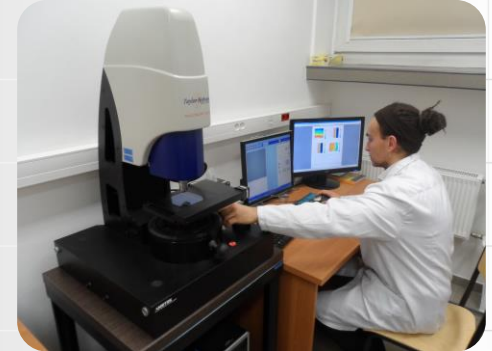
Main technological equipment:

- several vacuum deposition systems for thin films using:
 - Magnetron Sputtering (MS) (Balzers)
 - Electron Beam Evaporation (EBE) (SHINKU)
 - Ion Beam Assisted Deposition (IBAD) (Satis)
- wet (sol-gel, dip-coating) facility for deposition of thin films
- facility for preprocessing and post-deposition treatment of thin films (Nabertherm furnace)



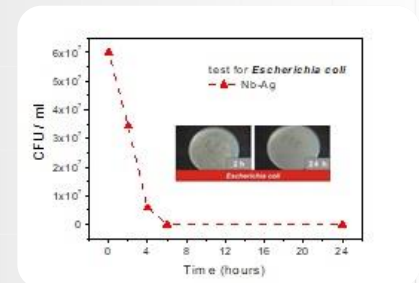
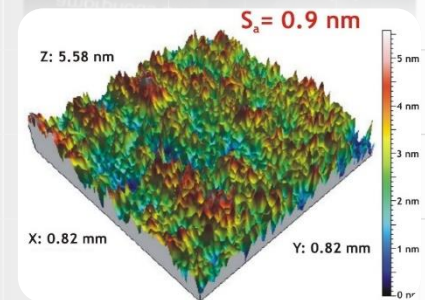
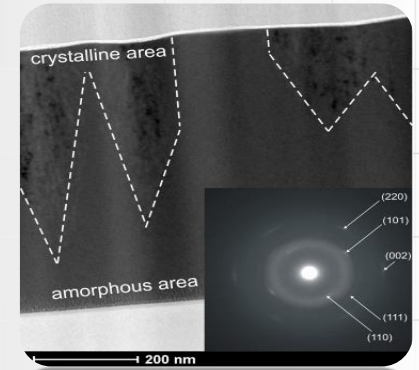
Thin film characterisation:

- Surface geometry measurements - Taylor Hobson Taly Surf CCI Lite optical profiler,
- I-V Keithley 4200 SCS Semiconductor Characterisation System (100 aA - 100 mA),
- Impedance spectroscopy setup Agilent 4294A
- Optical spectrophotometers and radiometers (Ocean Optics, Newport) 200 nm - 3200 nm,
- Setups for resistivity, Hall, Seebeck measurements (Jandel, Keithley, Instec),
- Physico-chemical properties of thin films (wetting angle, wear resistance ...),
- Setups for I-V characterisation of photovoltaic structures (Steuernagel Lichttechnik, class A solar simulator),
- Setup for Light Beam Induced Current, IR and VIS spectral mapping of photovoltaic structures,
- ...



Experience in analysis:

- Optical properties using reverse engineering (n&k nalysis, band-gap structure),
- Designing of optical thin film coatings,
- Microstructure (XRD, TEM, HRTEM),
- Elemental composition (EDS),
- Surface chemical properties (XPS, UPS),
- Surface geometry properties (AFM, optical profilometry),
- Gas-sensing properties,
- Impedance spectroscopy



List of selected Research and Applied grants:

- "A new approach to the development of a universal model of the gasochromic phenomenon based on a comprehensive analysis of the coloring mechanism in metal oxide thin films", 2021-2024
- "Analysis of electronic transport properties in a new generation gradient thin film memristor structures", 2019-2022
- "New materials in form of nanocrystalline thin films based on titanium with various copper content, of controlled antibacterial and cytotoxic properties", 2017-2021
- "Testing the hardness of optical coatings based on titanium obtained by innovative PVD methods
- "Study and analysis of the structure's impact on the functional properties of europium-doped nanocrystalline thin TiO₂ thin films", 2015-2017
- "Fabrication and characterization of electrical and optical properties of thin oxide films for transparent electronics", 2014-2017
- "Functional optical coatings for application in fireproof glass panes", 2013-2016

List of selected granted patents:

- Process for the preparation of TiO₂ thin films with high hardness and a thin layer of TiO₂ with increased hardness, Patent No PL232898B1, publication: 2019-08-30
- Method for producing thin-film resistance structures with memory effect and a thin-film resistance structure with memory effect, Patent No PL237258B1, Publication 2021-03-22
- Device for measuring properties of convex antistatic samples, Patent No PL223722B1, Publication 2016-10-31
- Method for layer application in multi-target magnetron sputtering system, Patent No PL221077B1, Publication 2016-02-29
- Urological stent, Patent No PL217535B1, Publication 2014-07-31
- Process for the preparation of transparent and conductive thin layer based on TiO₂ and thin transparent and conductive layer based on TiO₂, Patent No PL220544B1, Publication 2015-11-30
- Method of manufacturing thin layer with chrome gas effect, and the thin layer with chrome gas effect, Patent No PL217297B1, Publication 2014-07-31
- Production method of thin layer with thermal-resistance effect and a thin layer with thermal-resistance effect, Patent No PL216050B1, Publication 2014-02-28

Prof. Jaroslaw Domaradzki, PhD., DSc. Eng.

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